

Evaluation of Magnetic Structure of Ultrathin Mn₄N Films by X-Ray Magnetic Circular Dichroism Analysis

Mn₄N epitaxial thin films with a thickness of 4.2 nm were prepared on SrTiO₃(001) substrates. A thickness-dependent sign reversal of the anomalous Hall effect was observed. X-ray magnetic circular dichroism measurements at room temperature suggest that the magnetic structure of Mn₄N with a thickness of about 4 nm contains a noncollinear magnetic component different from that of conventional ferrimagnetic Mn₄N films. Furthermore, the ultrathin Mn₄N film exhibits smaller magnetization than the 24.7 nm thick Mn₄N film with a conventional magnetic structure, as confirmed by magneto-optical sum rule analysis.

Anti-perovskite Mn₄N is a candidate for current-driven domain wall (DW) motion devices such as a nonvolatile memory and a logic circuit. It exhibits a perpendicular anisotropy of $K_u \sim 0.1 \text{ MJ m}^{-3}$, a small spontaneous magnetization of $M_s \sim 80 \text{ kA m}^{-1}$ [1], and a high thermal stability with the Néel temperature of 740 °C [2]. Experiments with microstrips of Mn₄N-based materials demonstrated a high-speed DW motion driven by spin-transfer torques (STTs) at room temperature (RT) [1]. However, the current density for DW motion was large ($j > 3 \times 10^{11} \text{ A/m}^2$). To suppress the driving current, we have explored the use of spin-orbit torques (SOTs), which allows for more efficient DW motion than STTs. To achieve SOT-driven DW motion of Mn₄N without an external field, it is necessary to fabricate Mn₄N ultrathin films. In this study, we focused on the fabrication of Mn₄N ultrathin films on SrTiO₃(001) substrates and the evaluation of magnetic properties at room temperature (RT).

The SrTiO₃ substrates were etched with buffered HF solution to obtain a flat surface. The Mn₄N films were fabricated using the plasma-assisted molecular beam epitaxy method, where Mn atoms and N plasma were supplied simultaneously. The thickness

of the Mn₄N layer was controlled by the deposition time. They were determined as 24.7 nm for Sample A and 4.2 nm for Sample B by X-ray reflectometry (XRR) results shown in Fig. 1(a). After the deposition of Mn₄N, the reflection high-energy electron diffraction (RHEED) images were taken along the SrTiO₃[100] azimuth. They showed sharp streak patterns originating from the high-quality epitaxial growth of the Mn₄N layer on SrTiO₃(001) for both samples. The Mn₄N layer was covered by a SiO₂ capping layer deposited by radio-frequency sputtering to prevent the oxidation of Mn₄N. The surfaces of both samples were smooth as confirmed by atomic force microscopy (AFM). Figure 1(d) shows the result of the anomalous Hall effect (AHE) measurement when a magnetic field to the surface was applied. The thickness-dependent sign reversal in the AHE indicates a difference in magnetic structure.

Figures 2 show the results of X-ray absorption spectroscopy (XAS) and X-ray magnetic circular dichroism (XMCD) measurements for Mn $L_{2,3}$ absorption edges at RT. The measurements were performed by the total electron yield (TEY) method. Circularly polarized X-rays and a magnetic field of 5 T were applied from $\theta \sim 55^\circ$ (magic angle) relative to the surface

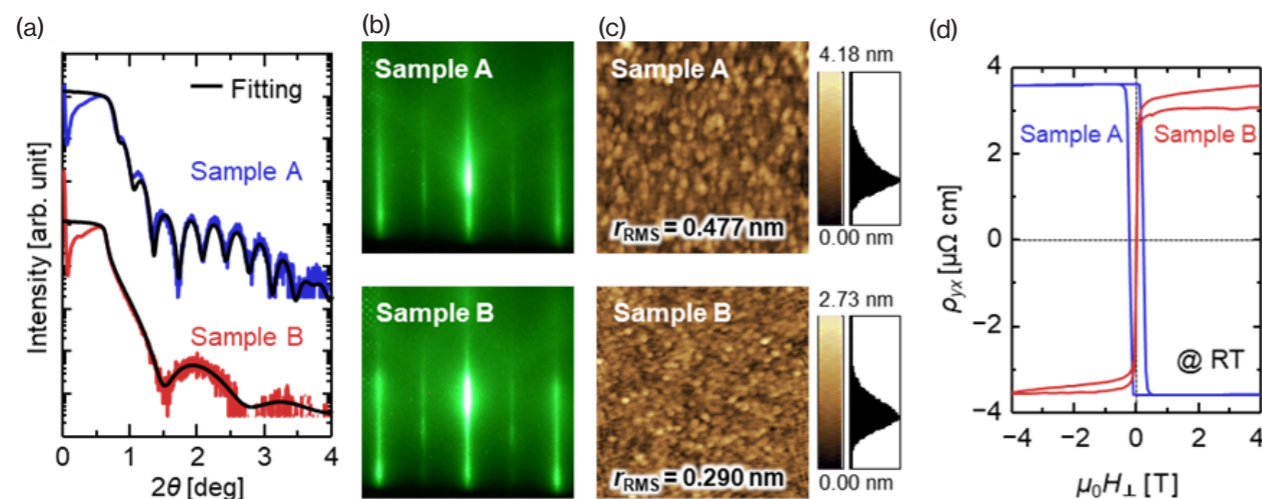


Figure 1: (a) XRR profiles and the fitting results. Blue and red lines indicate the measured profiles of Samples A and B, respectively. Black lines show fitting results. (b) RHEED images for Mn₄N layers along the SrTiO₃[100] azimuth. (c) AFM images with a scan range of 1 μm square. (d) Anomalous Hall resistivities ρ_{yx} at RT.

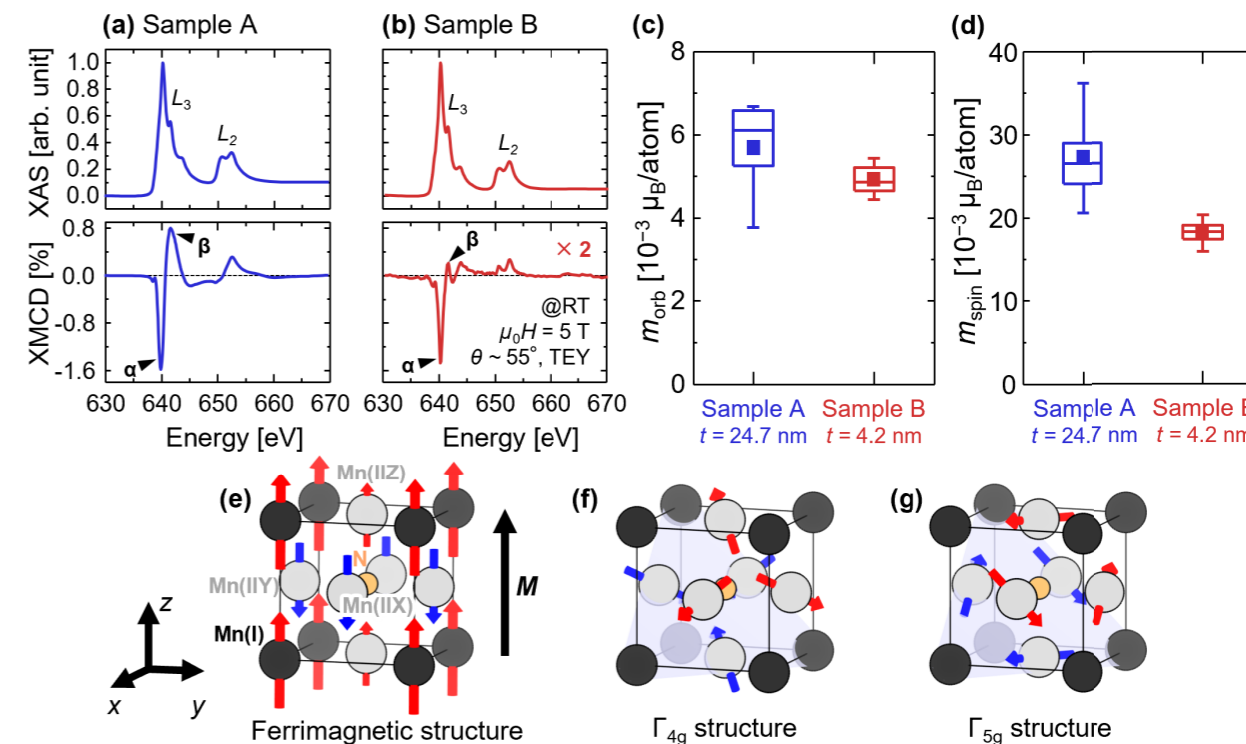


Figure 2: Results of XAS and XMCD measurements. (a, b) XAS and XMCD spectra of Samples A and B obtained at RT. (c) Orbital magnetic moments and (d) spin magnetic moments obtained using the magneto-optical sum rule. (e) Conventional ferrimagnetic structure of Mn₄N film. (f, g) Noncollinear magnetic structures of anti-perovskite crystal categorized as Γ_{4g} and Γ_{5g} .

normal. The XMCD spectrum of Sample A in Fig. 2(a) shows a profile attributed to the ferrimagnetism of Mn₄N (Fig. 2(e)). The negative sharp peak α in the Mn L_3 absorption edge is mainly derived from corner Mn(I) with a magnetic moment parallel to the magnetization. The positive broad peak β is mainly derived from face-centered Mn(II), (IIY) with antiparallel magnetic moments [3]. On the other hand, the XMCD spectrum of Sample B in Fig. 2(b) showed a reduced overall intensity. In particular, the peak α was visible at the L_3 absorption edge, but the peak β was significantly attenuated. These results suggest that the magnetic structure depends on the thickness of the Mn₄N layer. The orbital (Fig. 2(c)) and spin (Fig. 2(d)) magnetic moments of Mn atoms were calculated using the magneto-optical sum rule [4]. Focusing on spin magnetic moment m_{spin} which dominated the magnetization, it is evident that the m_{spin} of Sample B is smaller than that of Sample A. This may have been caused by changes in the magnetic structure and the Néel temperature. According to the literature by D. Fruchart *et al.* [5], the magnetic structure of bulk Mn₄N contains noncollinear texture components such as Γ_{4g} in Fig. 2(f) and Γ_{5g} in Fig. 2(g). For Mn₄N thin films, the noncollinear component is usually negligible, and a collinear ferrimagnetic structure (Fig. 2(e)) is often considered. However, in ultrathin Mn₄N films, the noncollinear component may become significant,

canceling the magnetic moment of Mn(II) and reducing the intensity of peak β in XMCD (Fig. 2(b)).

In summary, we have demonstrated the epitaxial growth of high-quality ultrathin Mn₄N films on SrTiO₃(001) substrates. The thickness-dependent change of magnetic structures was confirmed by AHE and XMCD spectra. The XMCD spectra of 4.2-nm-thick Mn₄N film indicated the presence of a noncollinear magnetic component.

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